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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Gonsalves, Kenneth E.  
Serial No. : 09/992,560  
For : **High Resolution Resists for Next  
Generation Lithographies**  
Filed : November 11, 2001  
Examiner : Lee, Sin J.  
Group Art Unit : 1752

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22311-1450

**AMENDMENT AND RESPONSE**

Applicant submits the following Amendment and Remarks in response to the  
Office Action mailed March 24, 2005 in the above-referenced application.

**Amendments to the Claims begin on page 2 of this paper.**

**Remarks begin on page 15 of this paper.**

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62 over claims 1, 3, 5, 6, 8, 10-13, 18-20, 22, and 23 of copending Application No. 10/324,642. Claims 1, 3, 5, 6, 8, 10-13, 18-22, and 23 of copending Application No. 10/324,642 may be amended during pendency of that application. If claims 1, 3, 5, 6, 8, 10-13, 18-20, 22, and 23 issue in a patent that would, in the opinion of the Examiner, sustain such an obviousness-type double patenting rejection, Applicant will respond to such a rejection when it is made.


For the foregoing reasons, Applicant respectfully requests that the provisional obviousness-type double patenting rejection of claims 22-25, 29-33, 35-46, 49-55, 58, 59, and 62 over claims 1, 3, 5, 6, 8, 10-13, 18-22, and 23 of copending Application No. 10/324,642 be withdrawn.

### CONCLUSION

In view of the foregoing Remarks, an allowance of the claims is respectfully solicited. The Examiner is respectfully invited to contact J. Clinton Wimbish at 336.607.7399 to discuss any matter related to this application.

Respectfully submitted,

6/9/05  
Date

  
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